



Working on the developing of a European standard for DD testing

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retour sur innovation

Context 1/3

- Some guidelines already exist
 - Total dose (ESCC 22900, MIL-STD-883G, method 1019.9)
 - Single events (ESCC 25100)
 - Some documents exist for displacement damage
 - Proton testing in general (“Proton Test Guideline – lessons learned” NASA NEPP document),
 - Displacement damage for imaging devices (“Displacement Damage Guideline,” ESA document 0195162),
 - But no equivalence to other test activities
⇒ Need of displacement damage guidelines

Context 2/3

- Why is there a lack of standardisation for displacement damages?
 - Do not concern all the device types
 - Mainly devices that interact or emit optical radiation (photonic or optoelectronic devices)
 - but also some other device types (bipolar transistors)
 - ⇒ limited list of device types
 - Wide range of materials (Silicon, GaAs, InGaAs, HgCdTe, InSb (Infrared detectors))
 - Wider domain of study
 - ⇒ More complex to interpret the result
 - Available literature not as large as for TID and SEE
 - Lesser technological interest
 - Difficulties in device testing (dedicated optical equipments, time consuming measurements)
 - High cost of devices

Context 3/3

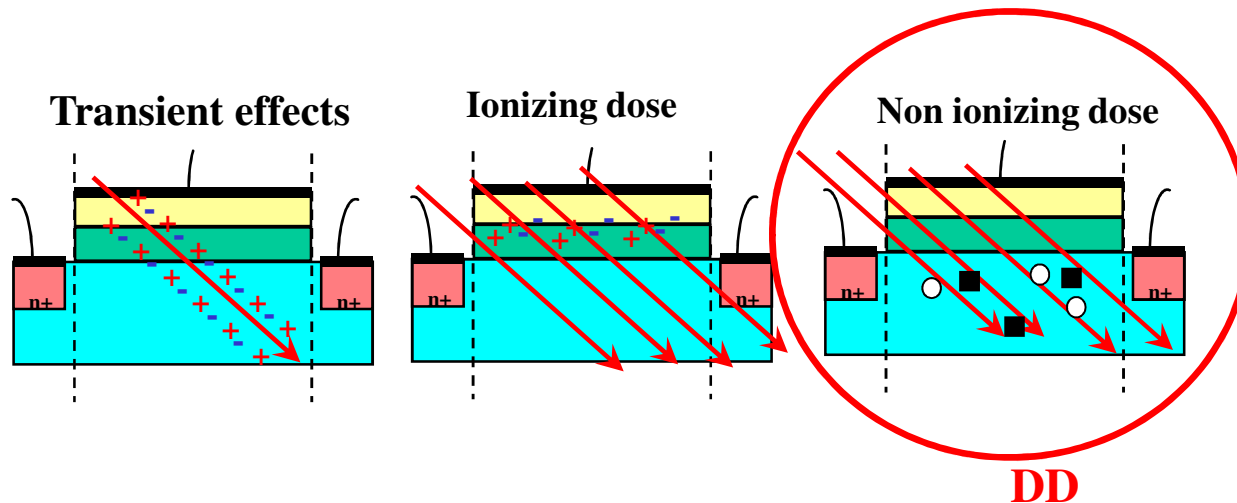
- Goal of the study
 - Propose a DD test standard
 - Should be available by the end of the year after ESA and Components Technology Board (*CTB*)/Radiation Working group (*RWG*) comments
- Goal of this presentation
 - ⇒ Not a draft of the future guidelines, but:
 - Remind the physical processes responsible of the displacement damages
 - Remind the electrical effects
 - List the main parameters that should be taken into account

Outline

- Displacement damage (DD) causes and effects
 - Particle-matter interaction
 - Displacement damage main effects
 - Introduction to NIEL parameter

- Key parameters for a displacement damage guideline from pre- to post-irradiation
 - Measured parameters,
 - Irradiation and dosimetry
 - Bias and annealing
 - ...

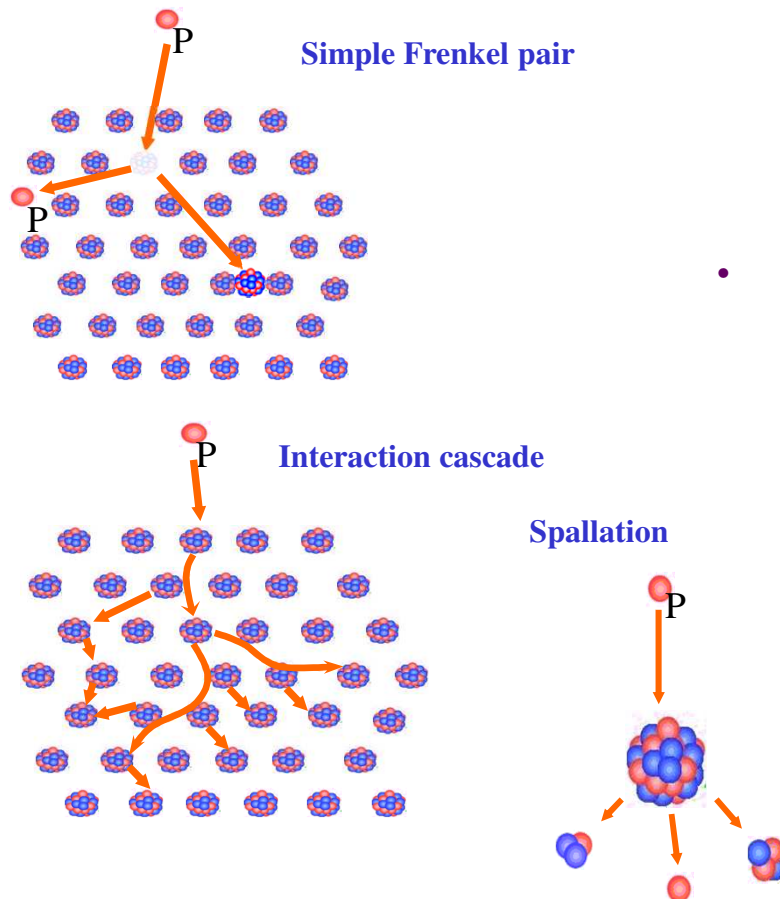
Energy transfer from particle to matter



- Particle slowed down by transferring energy to the matter
- Main part of the deposited energy is ionisation (interaction with the electrons), the rest is atomic displacements (interaction with the nuclei)
 - Fraction depends on particle type and energy, target material
 - Fraction decreases when the energy increases
- Displacement damage: degradation in the bulk of the device

Particle matter interaction for DD

Atomic Displacements: example of proton irradiation



- 3 main interaction types, different energy transfers
 - Coulombian
 - Nuclear elastic
 - Nuclear inelastic

Increasing transferred energy to the Primary Knock-on Atom and cascade size
- Consequence
 - Single displaced atom or interaction cascade
 - Creation of Frenkel pairs (vacancy-interstitial pairs) or more complex lattice defects (high concentration of deposited energy)
 - Reorganisation of these pairs into stable defects. Phase of "annealing"
 - Introduction of levels in the gap that modify the electrical properties of semiconductors

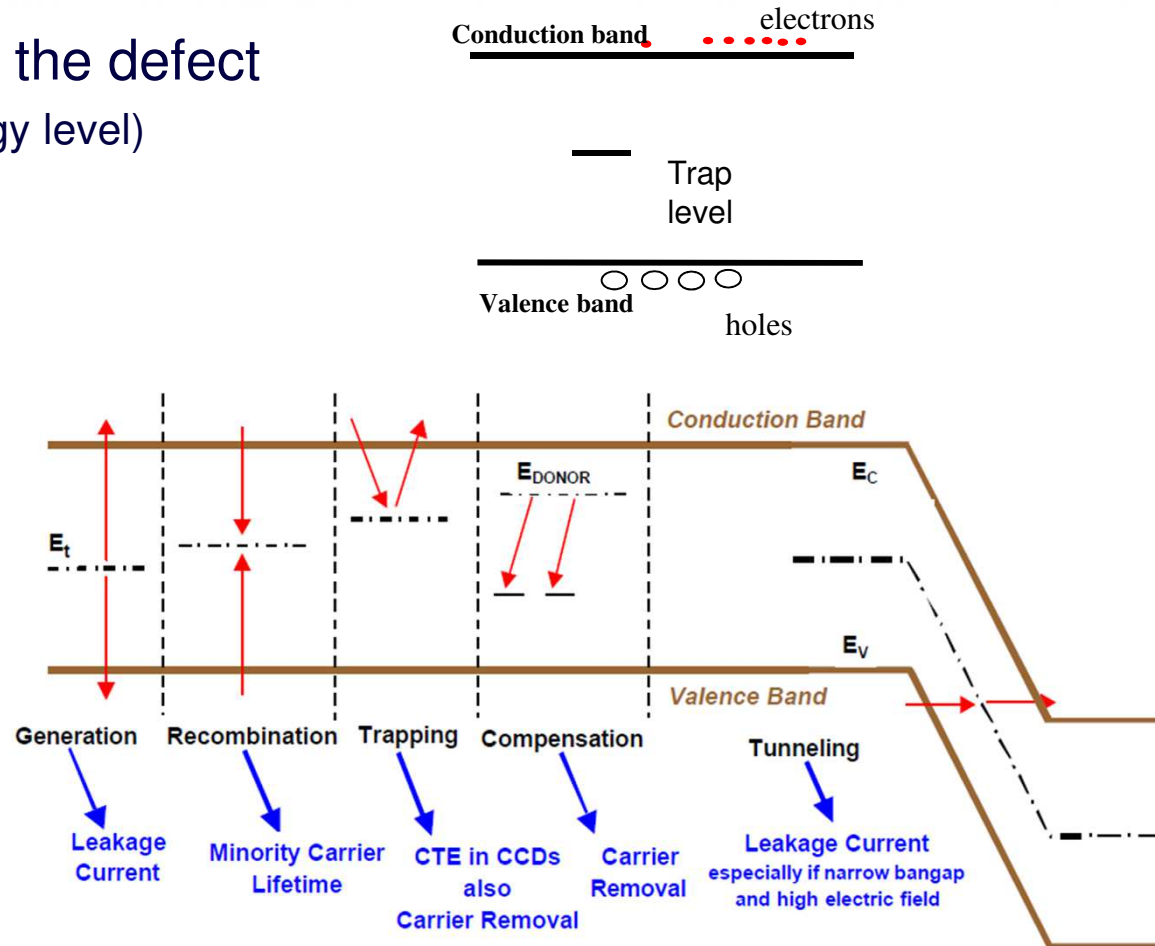
Degradation mechanisms

- Some parameters define the defect

- The position in the gap (energy level)
- The capture cross sections
- The emission rates

- The electrical effect depends on

- The defect density (degradation) and their parameters
- The carriers' concentration (state of the device)



G. Hopkinson, RADECS short course, 2003

Exemples of sensitive devices

- Solar cells
 - Output power
 - Short circuit current
 - Open circuit voltage
- Photodetectors
 - Leakage current (dark current),
 - Dark current non uniformity (DCNU) for arrays
 - Charge Transfer Efficiency (CTE) (CCDs)
 - Random Telegraph Signal (RTS)
- Bipolar transistors
 - Base current increase
 - Gain decrease
- Optocouplers
 - Ratio between input and output current (CTR) due to transistor and LED degradation
- LED
 - Light output decrease
- Laser Diodes
 - Thershold current increase

Non Ionizing Energy Loss (NIEL)

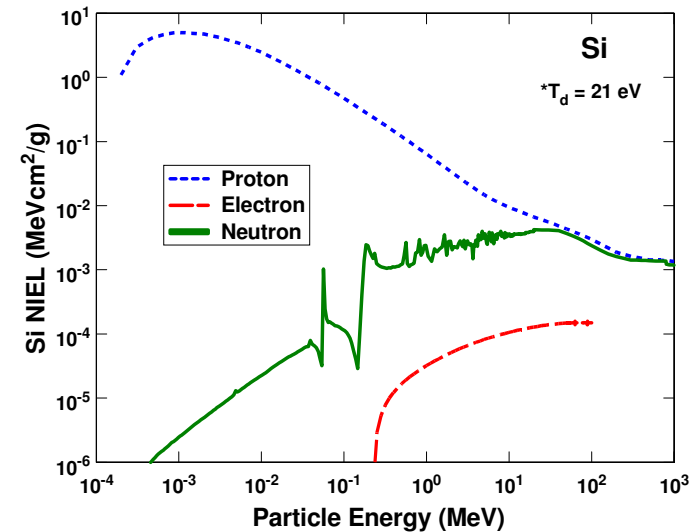
- NIEL

- Rate at which energy is lost to displacement
- Analogous to LET or stopping power for ionizing irradiation
- Unit MeV.cm²/g
- Depends on the target material, the particle type and energy
- NIEL is a mean parameter**

$$\text{NIEL}(E) = \frac{\eta}{\rho} \int_{T_d}^{T_{\max}} \left(\frac{\partial \sigma}{\partial T} \right) \text{T.L.}(T) dT$$

↑
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Differential cross section
Lindhardt fraction



- The displacement damage dose (DDD)

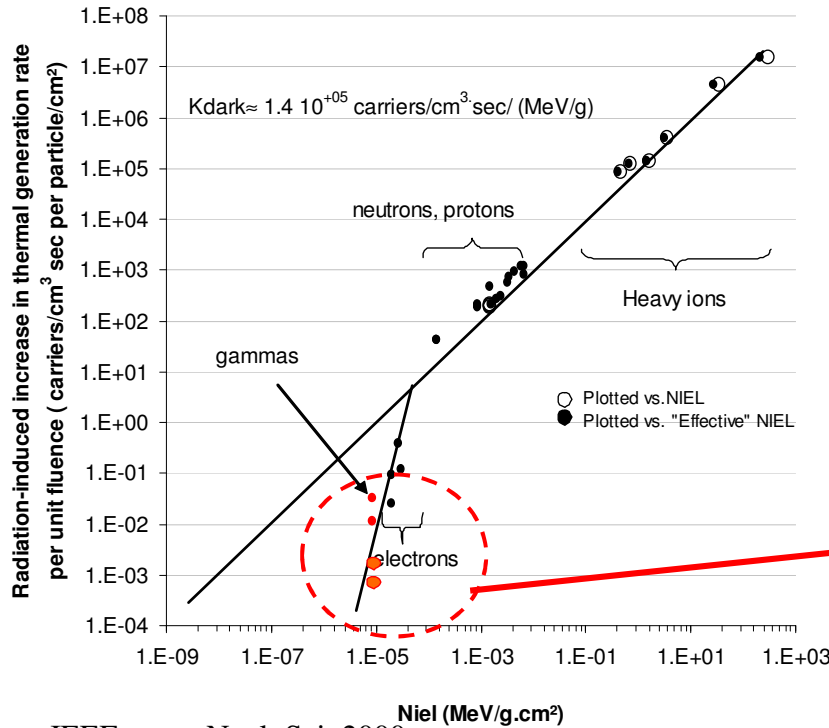
- For a monoenergetic irradiation: the product of the NIEL and the fluence
- For a spectrum of energy

$$\text{DDD} = \int_{E_{\min}}^{E_{\max}} \left(\frac{\partial \Phi}{\partial E} \right) \text{NIEL}(E) dE$$

- The NIEL and the DDD are used for correlating the displacement damages

- Various degradation models of electrical parameters with the DDD (linear, log...)
- Evaluate the degradation for a mission (spectrum) supposes
 - An equivalence of the degradation from energy to energy using a damage factor
 - Correlation between the damage factor and the NIEL
 ⇒ A good knowledge of the NIEL

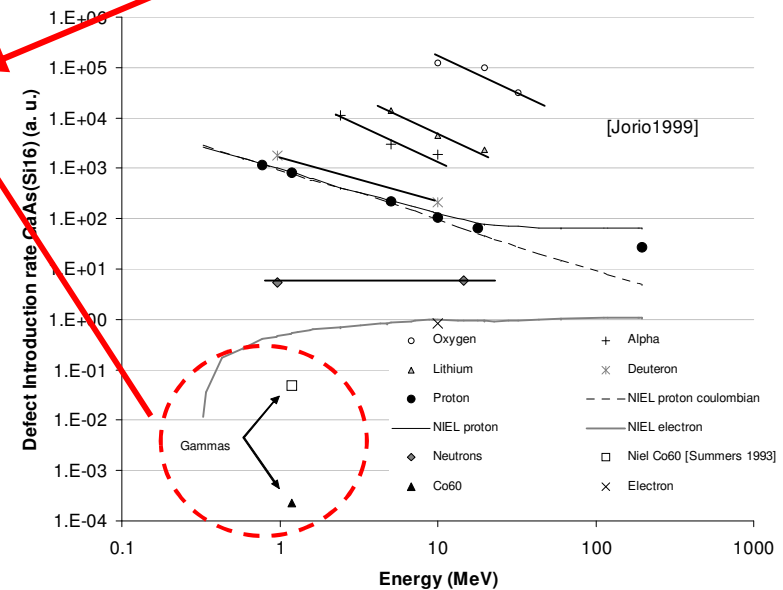
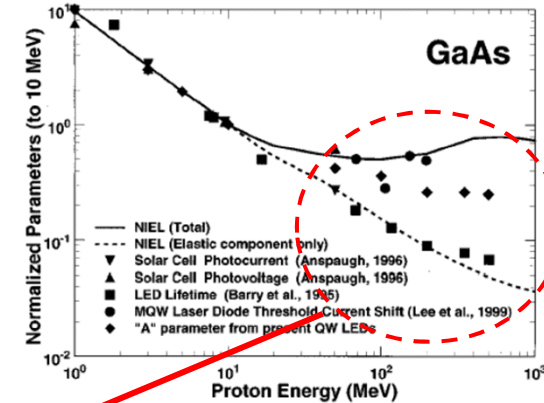
NIEL scaling law observed deviations



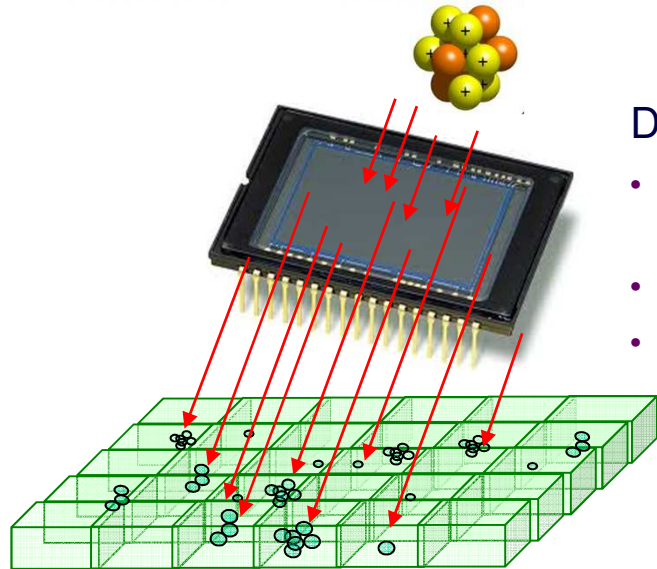
Srouf IEEE trans. Nucl. Sci. 2000

- NIEL for electrons ?**
- NIEL for gammas ?**
- Protons > 50 MeV in GaAs ?**
- Other materials (AlGaAS, InP, GaInP) ?**
- Different electrical parameters ?**

Walters et al. IEEE Trans. Nucl. Sci., vol. 48, pp. 1773-1777, 2001

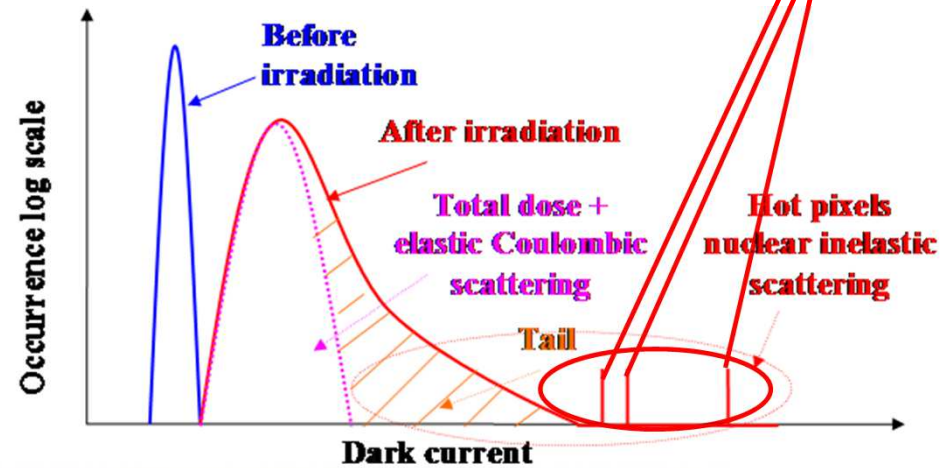
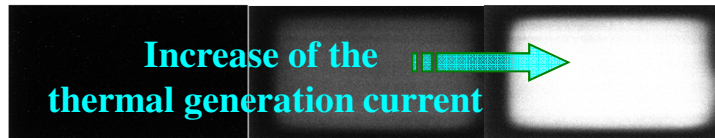
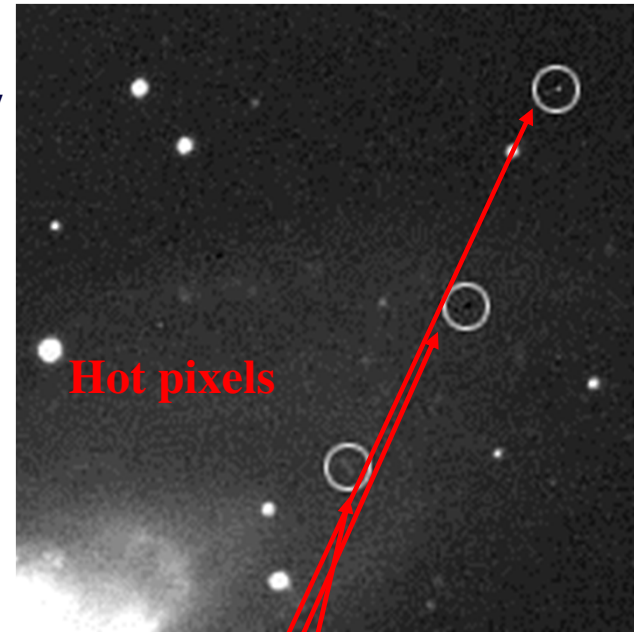
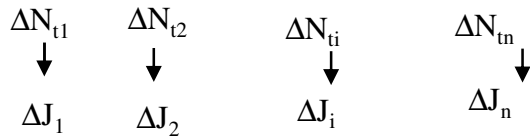


Limit of the NIEL: DCNU (Dark Current Non Uniformity) in Image sensors



Distribution of deposited energy

- Increase of the mean dark current
- Increase of DSNU
- Introduction of spikes (hot pixels)



Points to clarify in order to perform a test 1/3

- Before irradiation
 - Particle type and energy
 - Protons versus neutrons, electrons
 - Relevance / equivalence for the mission
 - Range issues
 - One energy (which one), several energies, spectrum
 - Fluence
 - Have relevant NIEL data for an equivalent DDD
 - margins
 - Parameters to measure
 - Sensitivity to displacement damages
 - Depends on the component type (e.g. imagers, optocouplers, LED, laser, photodiode...)
 - Conditions of measurement (temperature, levels...). Care should be taken when conditions change
 - Number of samples
 - Part-to-part and Lot-to-lot variations
 - Samples preparation

Points to clarify in order to perform a test 2/3

- During irradiation
 - Bias conditions
 - Impact of bias on the degradation
 - Dosimetry requirements in term of accuracy
 - Energy (ex. straggling for degraded beams)
 - Flux and fluence
 - Beam uniformity
 - Irradiation temperature
 - Accuracy
 - Relevance of room temperature for low temperature application
 - Need of intermediate measurements?
 - Evaluate the response with the fluence and/or the DDD: concept of damage factor
 - Caution: damage factor could depend on measurement conditions and time after irradiation
 - Flux effect?

Points to clarify in order to perform a test 3/3

- After irradiation
 - Delay between irradiation and measurement
 - Annealing considerations
 - Activation of the devices
 - Availability of the test equipment on the irradiation site
 - Storage conditions between irradiation and measurement
 - Prevent unexpected annealing effects
 - Bias conditions
 - Temperature

Conclusion

- Interests of DD guidelines
 - Help the people in charge of test
 - Definition
 - Conduction
 - Interpretation
 - Comparison
 - Hardness assurance tool
 - Should ensure a worst case of degradation
 - Trade-off between knowledges and technical constrains